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: 09/036,219 Application No. Filing Date : 03/06/1998 First Named Inventor: Kaichiro NAKANO : 1752 Group Art Unit : J. CHU **Examiner Name** Attorney Docket No.: NEKW 14.868

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r. i c	1	Isawa et al., "Novel Negative Photoresist Based on Polar Alicyclic Polymers for ArF Excimer Laser Lithography," Proceedings of Spie Reprint, Volume 3333, pgs. 417-424	
<u> </u>	2	(1998). Nakano et al., "Adhesion Characteristics of Alicyclic Polymers for Use in ArF Excimer Laser Lithography," Proceedings of Spie Reprint, Volume 3333, pgs. 43-52 (1998).	
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